AMENDMENT UNDER 37 C.F.R. §1.114(c)

U.S. Application No.: 10/656,124

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the

application:

LISTING OF CLAIMS:

(currently amended): A method for making three-dimensional structures of

nanometric or micrometric dimensions, wherein the three-dimensional structures are surface

projections having a height of up to 500 microns and having defined geometries, wherein the

method comprises the following steps:

(a) obtaining of a photopolymerizable mixture including nanoparticles orientable in

space;

(b) deposition of the mixture on a substrate to form a layer;

(c) exposure of the layer to UV-radiation to cause polymerization of the

photopolymeirzable mixture and control of state of polymerization by means of based on

variation of the index of refraction of the layer;

(d) application of a magnetic and/or electrical field to the layer to produce a desired

orientation or positioning of the nanoparticles and to induce the growth of the surface projections

from the layer; and

(e) polymerization of the mixture,

wherein the nanometric dimensions are dimensions from about 50 nm to 1 μ m, and the

micrometric dimensions are dimensions from about 50 µm to about 500 µm, and the control of

state of polymerization is carried out by detection of the variation of the index refraction of the

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intensity of the magnetic or electrical field.

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layer in the areas thereof having different degrees of cross-linking, to consequently modify

(previously presented): The method according to Claim 1, wherein the exposure 2.

of the layer to UV-radiation is concomitant with the application of the magnetic and/or electrical

field.

(previously presented): The method according to Claim 1, wherein the exposure 3.

of the layer of the mixture to UV-radiation and the application of the magnetic and/or electrical

field occur in an oxygen-free environment.

(previously presented): The method according to Claim 1, wherein the UV 4.

radiation is localized in the areas in which the surface projections are to be formed.

(previously presented): The method according to Claim 4, wherein the UV 5.

radiation is localized by means of a binary mask or a half-tone mask.

(previously presented): The method according to Claim 1, wherein the layer is 6.

exposed to non-uniform UV radiation, with a consequent non-uniformity in the formation of

polymeric lattice between areas of the layer most illuminated by UV radiation and areas of the

layer least illuminated by UV radiation.

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7. (canceled).

- 8. (previously presented): The method according to Claim 1, wherein the exposure of the layer to UV-radiation transforms the mixture from a liquid state to a gelatinous state.
- 9. (previously presented): The method, according to Claim 8, wherein the application of a magnetic and/or electrical field is carried out by application of a localized magnetic field by means of a magnetic tip.
- 10. (previously presented): The method according to Claim 9, wherein the tip has a nanometric dimension, is made of silicon, and is coated with a magnetic film, wherein the nanometric dimension is a dimension of 20-30 nm.
- 11. (previously presented): The method according to Claim 1, wherein the polymerization of the mixture is carried out by means of exposure thereof to UV radiation in the absence of application of the magnetic and/or electrical field.
- 12. (previously presented): The method according to Claim 11, wherein the polymerization of the mixture is carried out by means of localized exposure of the projections to UV radiation in the absence of the magnetic and/or electrical field.

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13. (previously presented): The method according to Claim 9, wherein the polymerization of the mixture is carried out by focusing a beam of UV radiation in the proximity of the tip to enable cross-linking of the projections.

- 14. (previously presented): The method according to Claim 1, wherein the photopolymerizable mixture comprises acrylated oligomers and monomers.
- 15. (previously presented): The method according to Claim 1, wherein the orientable nanoparticles are selected from the group consisting of ferrofluids, electro-rheological materials, liquid crystals and magneto-rheological materials.
- 16. (withdrawn): A solid component having three-dimensional surface structures of nanometric or micrometric dimensions, in particular having one or more surfaces in which there are defined projections having a height of up to 500 micron arranged according to definite geometries, obtained in accordance with the method according to claim 1.
- 17. (withdrawn): A solid component having at least one surface from which there rise projections having a height of up to 500 micron arranged according to definite geometries, wherein it is at least in part made using a photopolymer to which are added nanoparticles orientable in space by means of magnetic and/or electrical fields, the concentration of orientable nanoparticles being greater at the projections.

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18. (withdrawn): The component according to Claim 17, in which the photopolymer has a base of oligomers and monomers.

- 19. (withdrawn): The component according to Claim 17, in which the orientable nanoparticles are selected in the group consisting of ferrofluids, electro-rheological materials, liquid crystals and magneto-rheological materials.
- 20. (withdrawn): An apparatus for the implementation of the method according to Claim 1.
- 21. (withdrawn): The apparatus according to Claim 20, comprising:
 a support for deposition of a layer of a photopolymeric or UV mixture including
 nanoparticles orientable in space;
 - means for exposing the layer to UV-radiation;

means for controlling the polymerization of the mixture by means of variation of its index of refraction;

- means for applying a magnetic and/or electrical field capable of producing a desired orientation or positioning of the nanoparticles of the mixture in order to induce the growth of surface projections from the layer; and
 - means for carrying out polymerization of the mixture.

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22. (new): A method for making three-dimensional structures of micrometric dimensions, wherein the three-dimensional structures are surface projections having a height of up to 500 microns and having defined geometries, wherein the method comprises the following steps:

- (a) obtaining of a photopolymerizable mixture including nanoparticles orientable in space;
 - (b) deposition of the mixture on a substrate to form a layer;
- (c) exposure of the layer to UV-radiation to cause polymerization of the photopolymeirzable mixture and control of state of polymerization based on variation of the index of refraction of the layer;
- (d) application of a magnetic and/or electrical field to the layer to produce a desired orientation or positioning of the nanoparticles and to induce the growth of the surface projections from the layer; and
 - (e) polymerization of the mixture,

wherein the micrometric dimensions are dimensions from about 50 μ m to about 500 μ m, state of polymerization of the layer is controlled by monitoring variation of the index of refraction thereof, and consequently modifying intensity of the applied magnetic or electrical field,

and wherein

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the layer is exposed to non-uniform UV radiation, thereby producing a non-uniformity in polymeric lattice formation between areas of the layer most illuminated by UV radiation and areas of the layer least illuminated by UV radiation, and

variation of the index refraction is monitored by detecting intensity distribution of orders of diffraction in areas of the layer having different degrees of cross-linking.

- 23. (new): A method for making three-dimensional structures of nanometric dimensions, wherein the three-dimensional structures are surface projections having a height of up to 1 micron and having defined geometries, wherein the method comprises the following steps:
- (a) obtaining of a photopolymerizable mixture including nanoparticles orientable in space;
 - (b) deposition of the mixture on a substrate to form a layer;
- (c) exposure of the layer to UV-radiation to initially transform the photopolymerizable mixture from a liquid state to a gelatinous state, and control of polymerization state of the layer;
- (d) application of a magnetic field to the layer to produce a desired orientation or positioning of the nanoparticles and to induce the growth of the surface projections from the layer; and
 - (e) conclusive polymerization of the mixture,

wherein the nanometric dimensions are dimensions from about 50 nm to 1 µm,

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step (d) comprises application of a localized magnetic field to the layer by means of a magnetic tip to induce growth of a projection from the layer, and

step (e) comprises focusing a beam of UV-radiation in the proximity of the tip, to cause cross-linking of the projection.